# **Recent development of finely** segmented AC-LGAD sensors

High Energy Physics Laboratory

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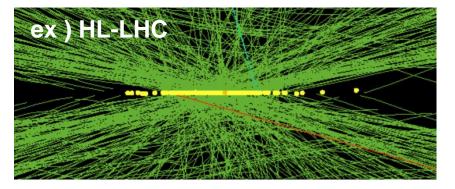
University of Tsukuba

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### Motivation

### Issues

Future hadron collider  $\rightarrow \rightarrow$  High luminosity



HL-LHC : 200 interactions in an event FCC : **1500** interactions in an event

At high luminosity collider, inner tracker has problems

1. Pile up

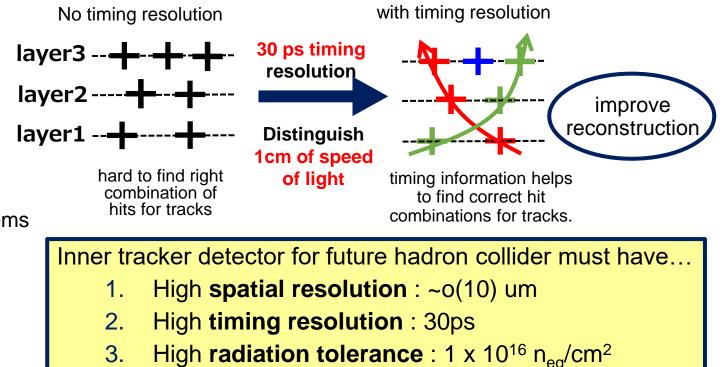
2.

- High occupancy
- 3. High radiation need radiation tolerance

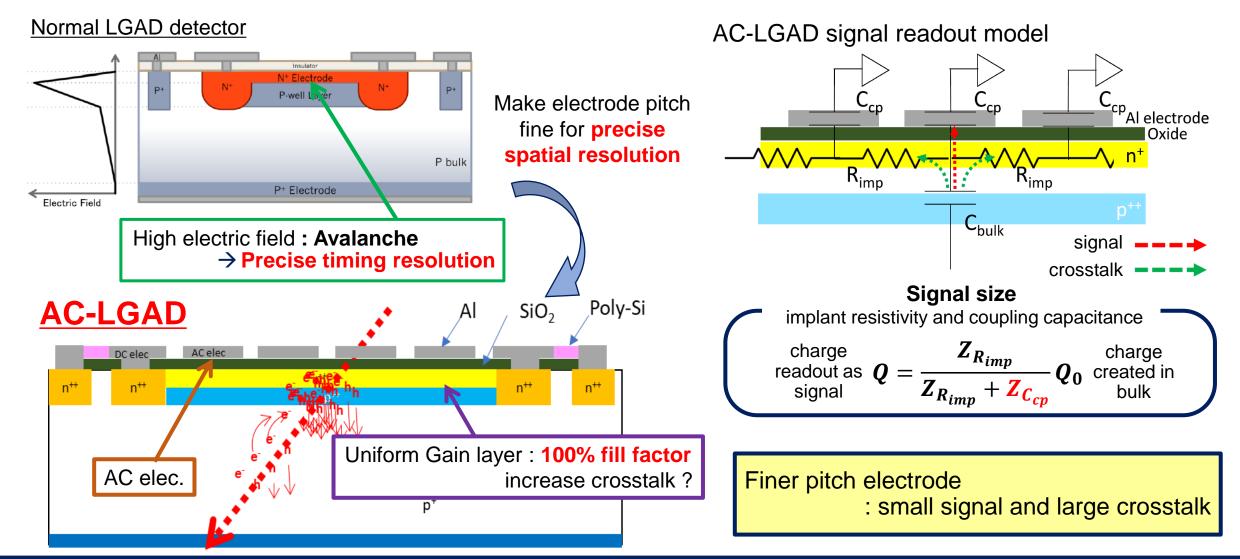
### solution

Tracking detector with **30ps timing resolution** is one solution.

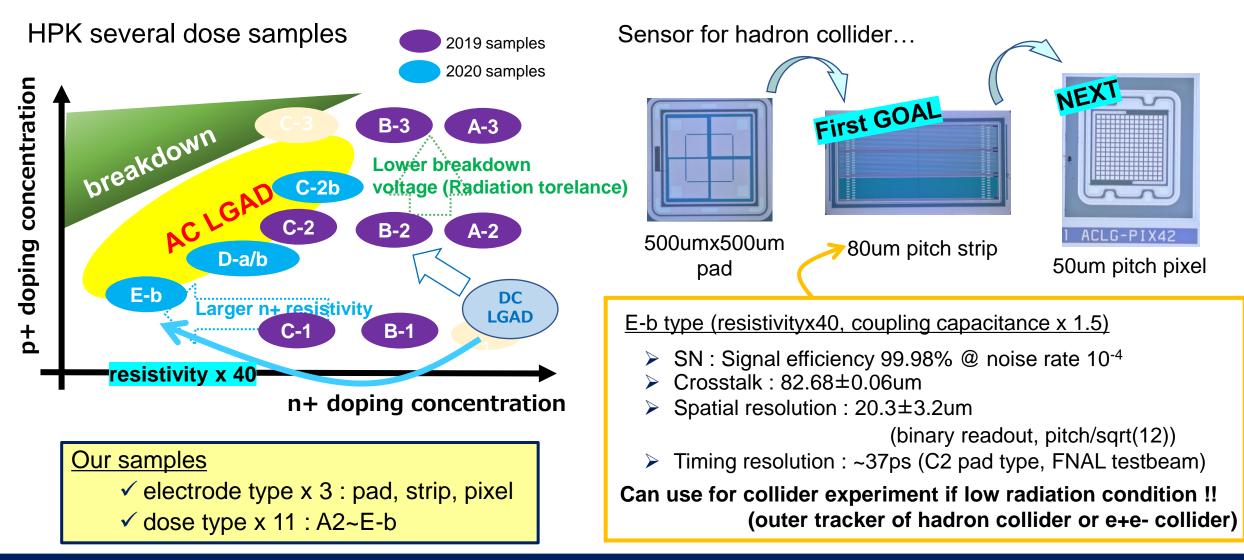
multi-layer tracking detector

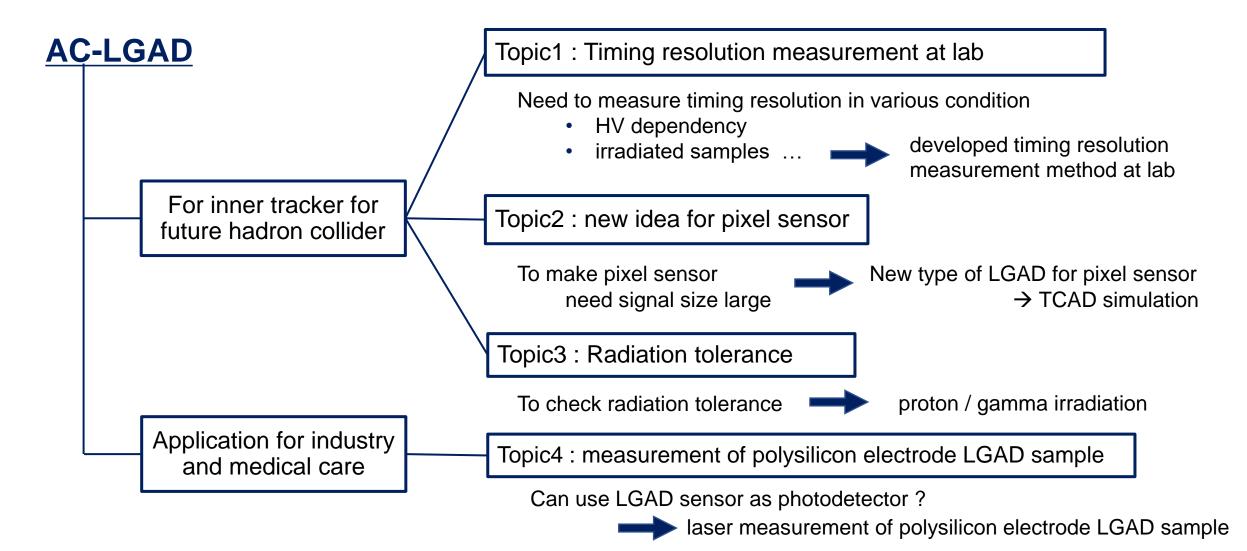


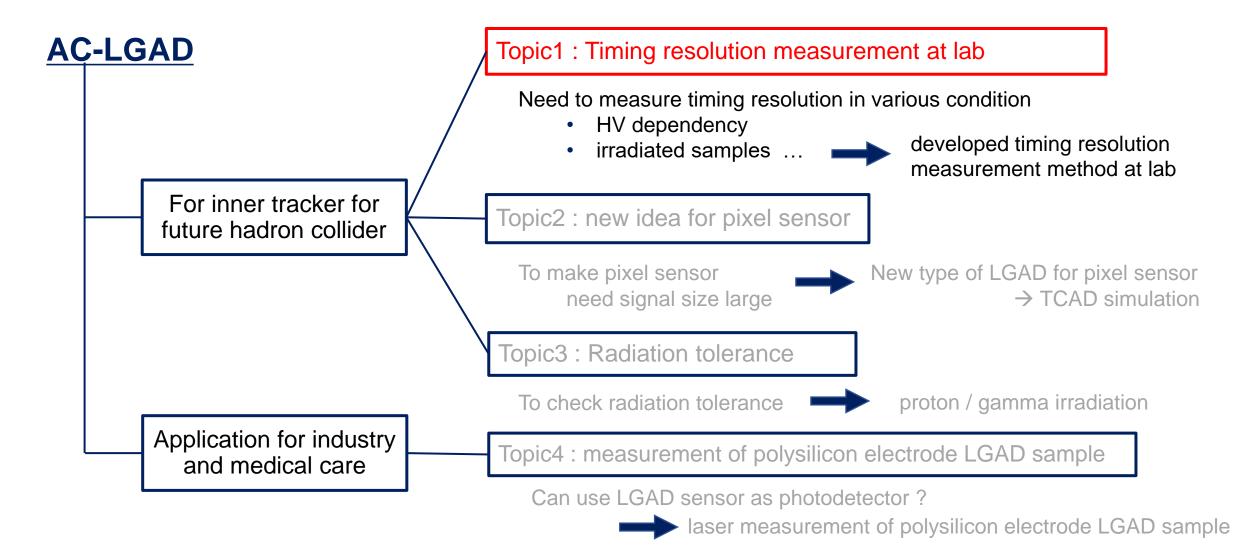
### Low-Gain Avalanche Diode detector



### **Goal and samples**

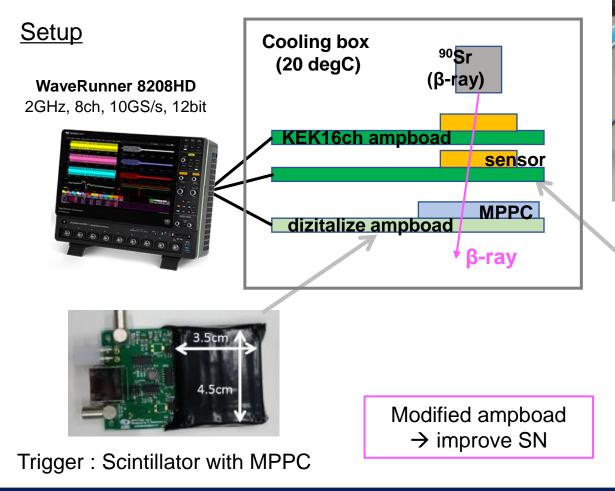


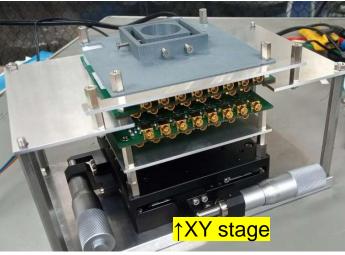




## **Timing resolution measurement**

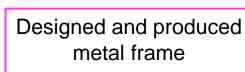
Timing resolution : calculated time difference of two stacked sensors





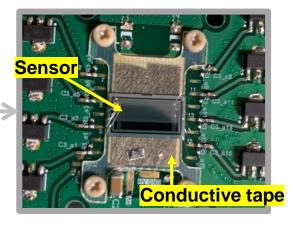
#### KEK 16ch ampboad





Pad sensor (500x500um)

- → get closer distance of two sensors
- → align position precisely

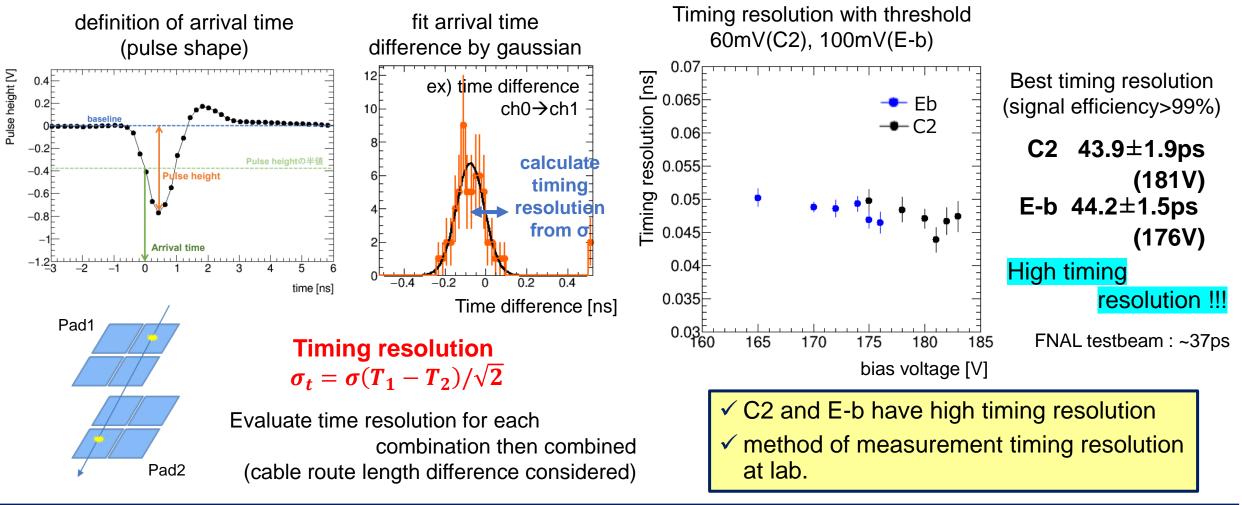


## **Timing resolution measurement**

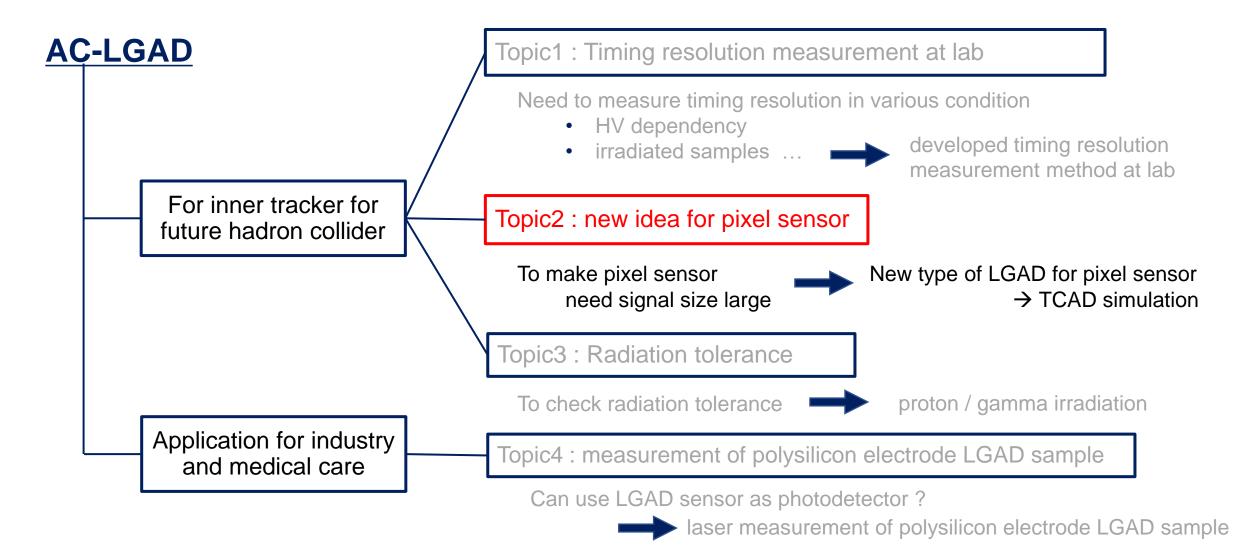
#### Pad sensor(500x500um)

resistivity E-b : high C2 : low

### Analysis

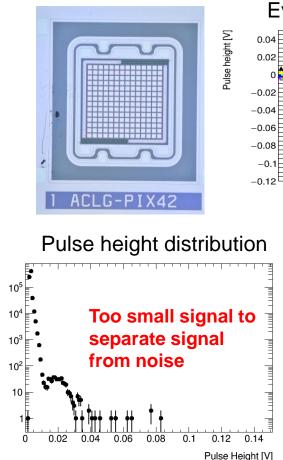


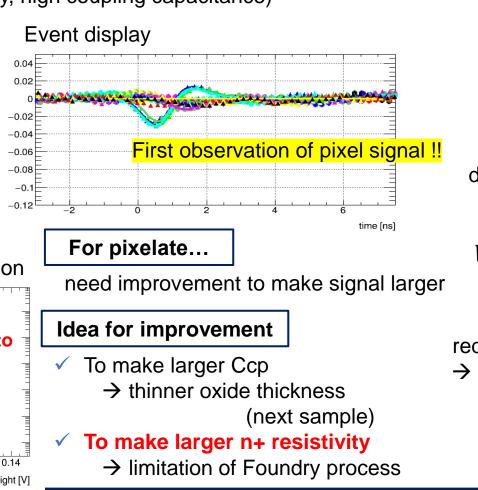
> Result



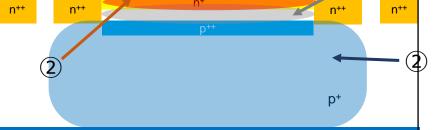
## Pixel sensor challenge!

Toward fine pitch...  $\rightarrow$  50um pitch pixel sensor E-b type (high resistivity, high coupling capacitance)





depletion region : deplete  $(1) \rightarrow (2)$ 



depleted region is spread into n+ layer

$$N_n = \sqrt{\frac{2\epsilon}{eN_D}} \frac{1}{1 + \frac{N_D}{N_A}} V_D$$

ε : permittivity

e : elementary charge

V<sub>D</sub>: Diffusion potential

 $N_A$ : p+ doping concentration

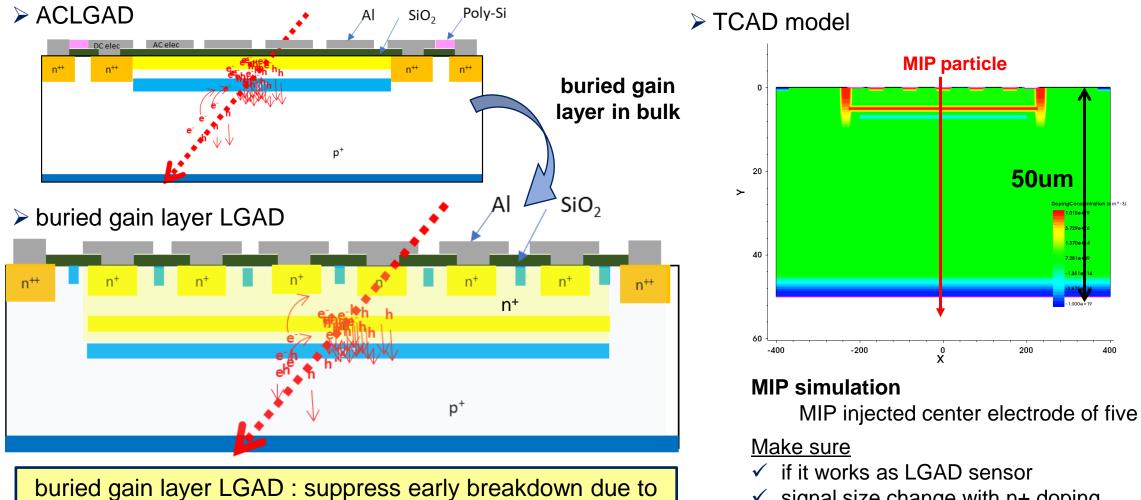
 $N_{D}$ : n+ + doping concentration

reduce n+ doping concentration (=large n+ resistivity) → early breakdown due to reaching depletion layer to front surface.

Need some idea to make signal larger for pixel sensor...

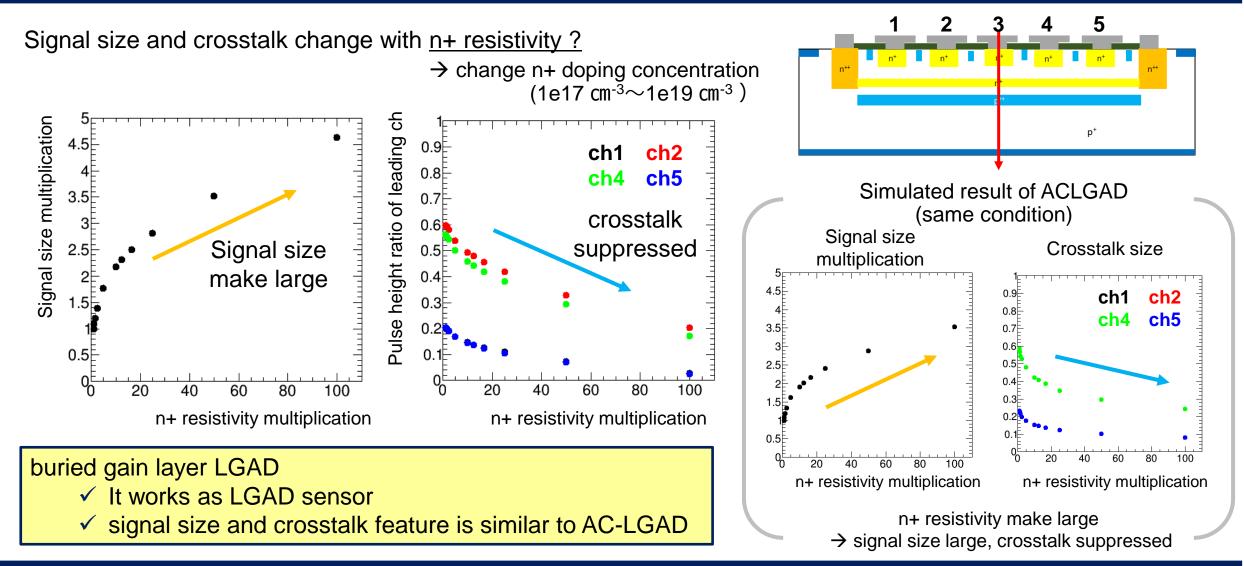
## New idea and simulation model

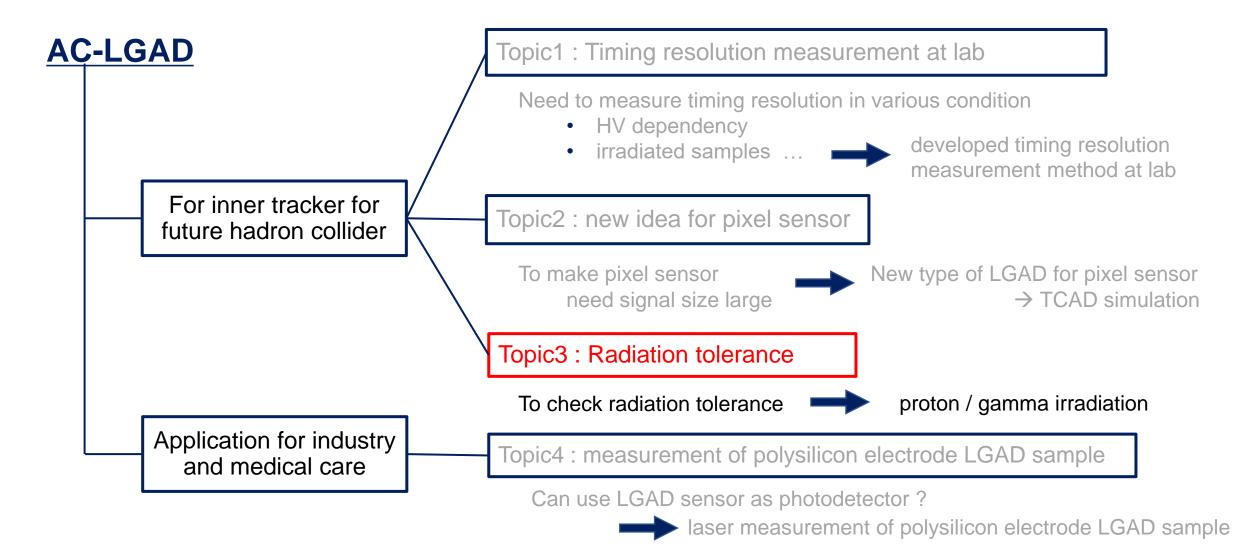
reach depletion layer to surface of the sensor ??



 signal size change with n+ doping concentration ?

## Signal size and crosstalk simulations



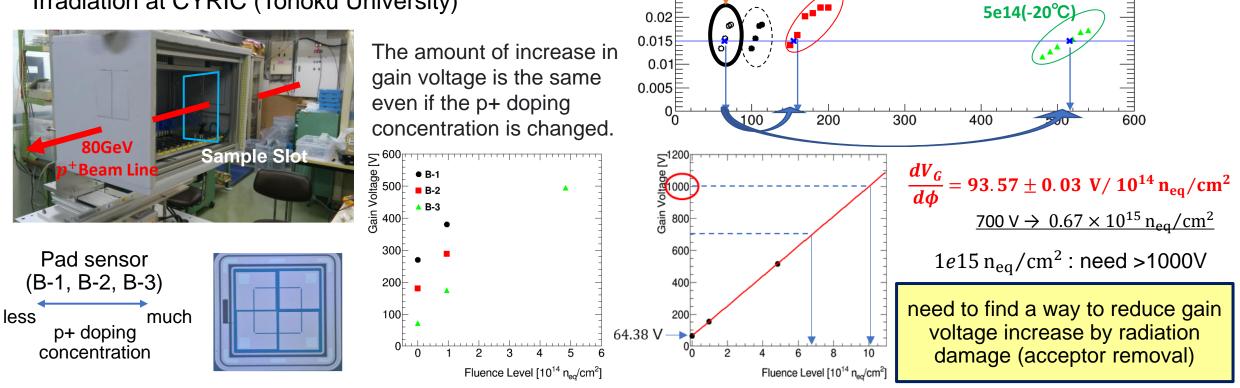


## **Proton irradiation sample**

### Radiation damage

- ✓ NIEL : Bulk damage
- ✓ TID : Surface damage
- acceptor removal (decrease p+ doping conc)

Irradiation at CYRIC (Tohoku University)



0.05

0.045

0.04E

0.035

0.025

33 non-irrad (20° C) B3 1e14 n<sub>an</sub> / cm<sup>2</sup> (-20° C)

non-irad

0.03 **E**(-20°C correction)

B3 5e14 n<sub>en</sub> / cm<sup>2</sup> (-20° C)

Signal MPV [V]

Signal size vs bias voltage (B-3 type)

1e14(-20°C)

Signal size remain after irradiation

## Gamma irradiation sample

### Radiation damage

- ✓ NIEL : Bulk damage
- TID : Surface damage
- acceptor removal (decrease p+ doping conc)

### Irradiation at facility in Takasaki

0.12

0.1

0.08

0.06

0.04

0.02

••

0.01



#### <sup>o</sup>ulse Height Ratio to Leading strip non-irrad 0.8 0.6 0.4 Signal size 8 0.14 non-irrad

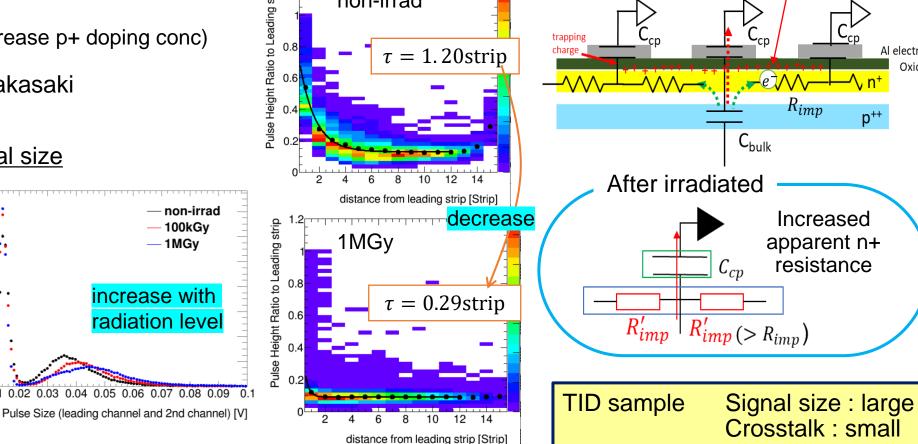
- 100kGv

— 1MGy

increase with

radiation level

0.02 0.03 0.04 0.05 0.06 0.07 0.08 0.09



**Crosstalk** 

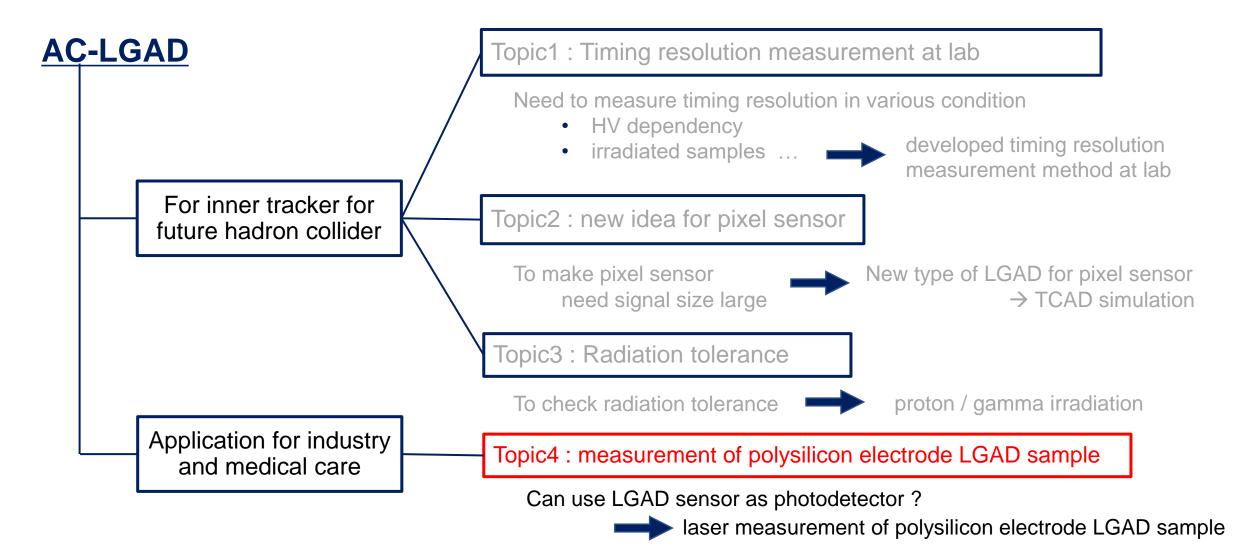
Strip sensor (E-b)

**TID** damage (positive trapping charge)

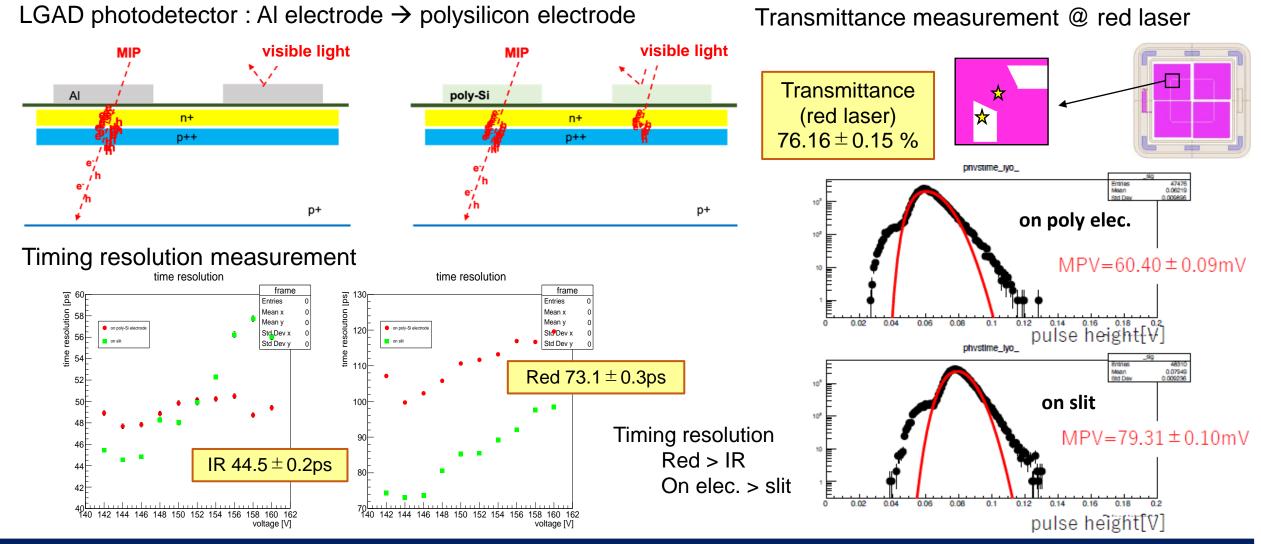
Al electrode

p++

Oxide



## **Application to LGAD photodetector**



## Signal attenuation by electrodes

#### Testbeam @ ELPH Signal readout model (polysilicon elec. version) efficiency map efficiency R<sub>strip</sub> frame projection Y Y[mm], Mean v Std Dev x Std Dev v wirebond pad 0.3 region 0.25 0.2 -16 0.15 **Ŗ<sub>i∭P</sub> D**imp 0.1 -18 0.05 -20 LGAD position 0.333 0.6 **C**<sub>bulk</sub> $y = Aexp\left(-\frac{x}{\tau}\right) + B$ ••X[mm] Signal size : poly-Si elec. < Al elec. $0.23 \pm 0.05 mm$ ✓ Signal cannot separate from noise. $R_{strip} = 182\Omega/\mu m$ ✓ Reason : Large resistance of poly-(stripの幅が35umの時) Si ?? Signal was attenuated due to the resistance $Q = \frac{Z_{R_{imp}}}{Z_{R_{imp}} + Z_{C_{cp}} + Z_{R_{strip}}} Q_0$ of poly-Si elec. itself $\rightarrow$ make sample with reduced polysilicon resistance Z<sub>Rstrip</sub> increases in proportion to the distance from the wirebond pad

#### **TCHoU Workshop, Photon & Particle Detectors Division**

Strip sensor (80um pitch)

### Conclusion

LGAD detector : precise timing and position resolution

Topic1 : Method of timing resolution measurement at lab

Timing resolution measurement C2 43.9±1.9ps (181V) E-b 44.2±1.5ps (176V)

Established method of timing resolution measurement at lab

Important step for developing

Topic2 : new idea for pixel sensor

buried gain layer LGAD

TCAD simulation  $\rightarrow$  confirm to work as a sensor

produce prototype sample

Topic3 : Radiation tolerance

Proton irradiation

Signal size : not reduced Gain voltage : large



need improvement for hadron collider

Gamma irradiate

Signal size : larger crosstalk : smaller

Topic4 : measurement of polysilicon electrode LGAD sample

Measurement poly-Si elec. sample

Transmittance :  $76.16 \pm 0.15$  % (red laser) Timing resolution :  $44.5 \pm 0.2$ ps (IR laser)

Serious study for the application is performed